

Japan TC Chapter Compound Semiconductor Materials Global Technical Committee

Liaison Report

Jun. 15, 2021

v1

Meeting Information

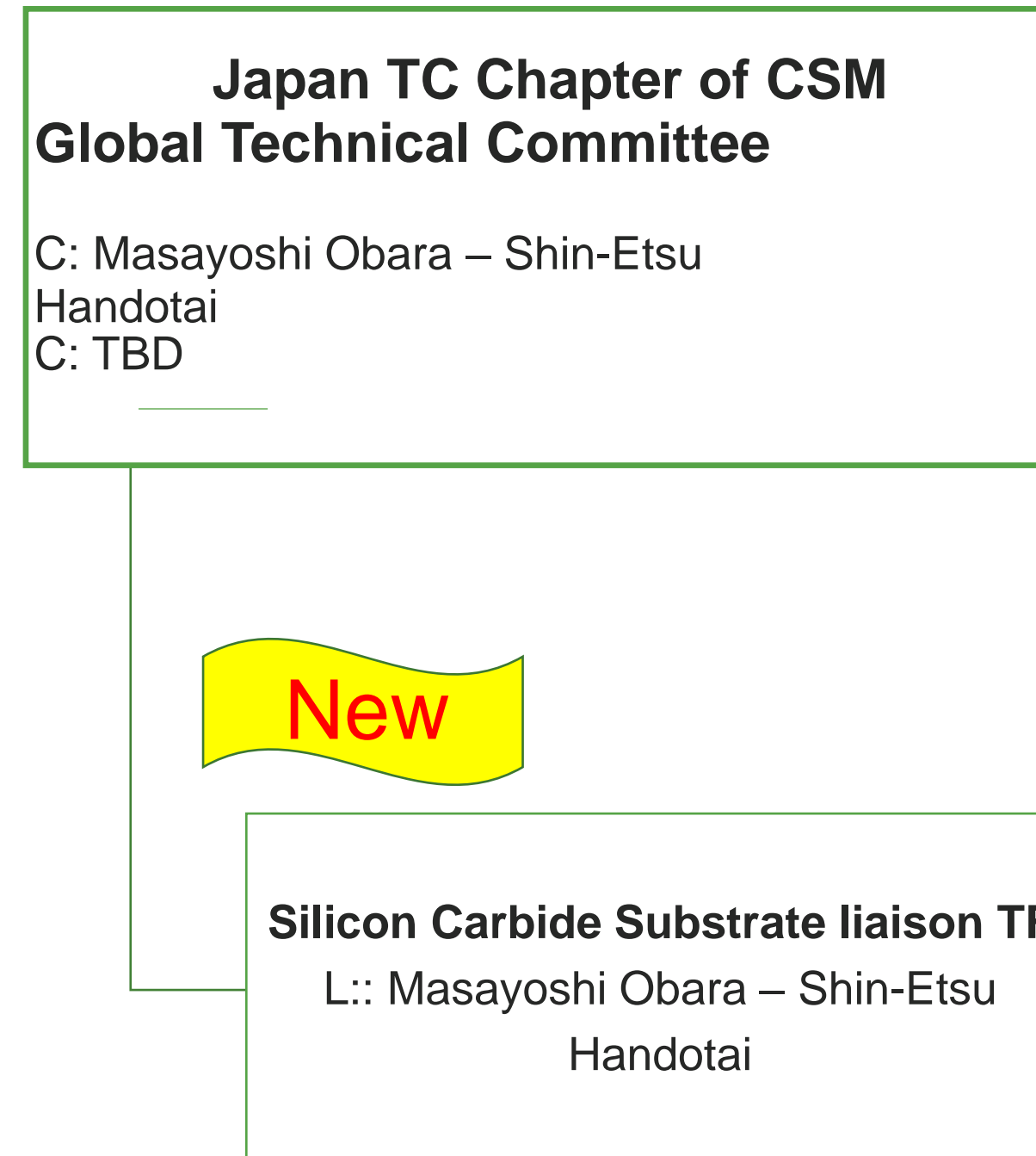
- Last meeting
 - May 26, 2021 at Japan Spring 2021 Meetings
 - Web Conference
- Next meeting
 - Jan. 19, 2022 at Japan Winter 2022 Meetings
 - Web Conference

<http://www.semi.org/en/standards-events>

Leadership

- Co-Chairs: Masayoshi Obara (Shin-Etsu Handotai Co., Ltd.)

Organization Chart



New TFOF



- **Silicon Carbide Substrate liaison TF**

- Charter: Discussions will be held in Japan to support and complement Silicon Carbide materials revision and new standards development activities in other regions.
- Scope: To cover the scope of the Silicon Carbide Substrate Task Force for its on existing SEMI Silicon Carbide Standards and new Standards as such become necessary.

Ballot Review

Doc #	Document Title	TC Chapter Action
None		

#1: Passed ballots and line items will be submitted to the ISC Audit & Review Subcommittee for procedural review.

#2: Failed ballots and line items were returned to the originating task forces for re-work and re-balloting or abandoning.

Authorized Activities

Doc #	Type	SC/TF/WG	Details
None			

Task Force Highlights

- The Japan TC Chapter discharged four Inactive TFs in the last Japan TC Chapter Meetings.
- The Japan TC Chapter approved a New TFOF ‘ Silicon Carbide Substrate Liaison TF’. Please refer the New TFOF page.

5-Year Review

Designation #	Standard Title	Action By	Assigned to
None			

Thank you!

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